Notice of Allowability	Application No.	Applicant(s)
	00/000 000	
	09/632,388 Examiner	LI ET AL. Art Unit
	Julio J. Maldonado	2823
The MAILING DATE of this communication appear All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this ap or other appropriate communication GHTS. This application is subject to	plication. If not included
1. This communication is responsive to <u>response filed on July</u>	/ 25, 2003.	
2. The allowed claim(s) is/are <u>1-4,6,7,9,10,20 and 22-28</u> .		
3. The drawings filed on are accepted by the Examine		
 4. ☐ Acknowledgment is made of a claim for foreign priority und a) ☐ All b) ☐ Some* c) ☐ None of the: 		
 Certified copies of the priority documents have 		
2. Certified copies of the priority documents have		
 Copies of the certified copies of the priority doc International Bureau (PCT Rule 17.2(a)). 	cuments have been received in this	national stage application from the
* Certified copies not received:		
5. Acknowledgment is made of a claim for domestic priority un	ider 35 U.S.C. § 119(e) (to a provisi	onal application).
 (a) ☐ The translation of the foreign language provisional age 6. ☐ Acknowledgment is made of a claim for domestic priority un 		
o	der 35 U.S.C. §§ 120 and/or 121.	
Applicant has THREE MONTHS FROM THE "MAILING DATE" of below. Failure to timely comply will result in ABANDONMENT of the	this communication to file a reply co his application. THIS THREE-MON	mplying with the requirements noted
7. A SUBSTITUTE OATH OR DECLARATION must be submi	tted Note the attached EXAMINER	'S AMENDMENT OF NOTICE OF
 8. ☐ CORRECTED DRAWINGS must be submitted. (a) ☐ including changes required by the Notice of Draftspers. 1) ☐ hereto or 2) ☐ to Paper No (b) ☐ including changes required by the proposed drawing composed (c) ☐ including changes required by the attached Examiner's 	orrection filed, which has be	en approved by the Examiner
(9) El moldanig changes required by the attached Examiller's	Amendment / Comment or in the C	ffice action of Paper No
Identifying indicia such as the application number (see 37 CFR 1.8 each sheet.	4(c)) should be written on the drawing	gs in the front (not the back) of
9. ☐ DEPOSIT OF and/or INFORMATION about the deposing attached Examiner's comment regarding REQUIREMENT FOR TH	it of BIOLOGICAL MATERIAL m IE DEPOSIT OF BIOLOGICAL MAT	ust be submitted. Note the 'ERIAL.
Attachment(s)		
 Notice of References Cited (PTO-892) Notice of Draftperson's Patent Drawing Review (PTO-948) Information Disclosure Statements (PTO-1449), Paper No Examiner's Comment Regarding Requirement for Deposit of Biological Material 	4□ Interview Summa 6□ Examiner's Amen	Patent Application (PTO-152) ry (PTO-413), Paper No dment/Comment ment of Reasons for Allowance

DETAILED ACTION

1. The non-final rejection as set forth in paper mailed on 05/22/2003 is withdrawn in response to applicants' request for reconsideration.

2. Claims 1-4, 6, 7, 9, 10, 20 and 22-28 are pending in the application.

Allowable Subject Matter

- 3. Claims 1-4, 6, 7, 9, 10, 20 and 22-28 are allowed.
- 4. The following is an examiner's statement of reasons for allowance:

The prior art of record, Ngo et al. to 6,127,261 teach in Figs.1-3 and related text an interlayer dielectric layered structure including a substrate (102); a first dielectric layer (104) disposed over the substrate (102); a layer of undoped silicate glass (112) disposed on the dielectric layer (104); an unplanar layer of borophosphorous silicate glass (114) disposed on the layer of undoped silicate glass (112), said planar layer having an uppermost surface; and a planar dielectric layer (110) of plasma enhanced tetraethylorthosilicate glass disposed on the unplanar layer of borophosphorous silicate glass (114), said planar dielectric layer (110) having an uppermost surface substantially even with the uppermost surface of said unplanar layer of borophosphorous silicate glass (114), the borophosphorous silicate glass layer (114) and the planarized layer of plasma-enhanced tetraethyl orthosilicate layer (110) together forming a pre-metal dielectric layer (column 1, line 29 – column 5, line 15).

However, Ngo et al. teach a planarized PETEOS layer without exposing the BPSG layer, which is opposed to the claimed invention.

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Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

5. Papers related to this application may be submitted directly to Art Unit 2823 by facsimile transmission. Papers should be faxed to Art Unit 2823 via the Art Unit 2823 Fax Center located in Crystal Plaza 4, room 3C23. The faxing of such papers must conform to the notice published in the Official Gazette, 1096 OG 30 (15 November 1989). The Art Unit 2823 Fax Center number is (703) 305-3432. The Art Unit 2823 Fax Center is to be used only for papers related to Art Unit 2823 applications.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to **Julio J. Maldonado** at **(703) 306-0098** and between the hours of 8:00 AM to 4:00 PM (Eastern Standard Time) Monday through Friday or by e-mail via julio.maldonado@uspto.gov. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri, can be reached on **(703)** 306-2794.

Any inquiry of a general nature or relating to the status of this application should be directed to the **Group 2800 Receptionist** at **(703) 308-0956**.

JMR 9/20/03

> George Fourson Primary Examiner